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STRUCTURAL-PHASE TRANSFORMATIONS IN «Cr/SILUMIN» SYSTEM UNDER PLASMA AND THERMAL IMPACT

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The investigation of structural-phase transformations under thermal treatment in the near-surface layer of the eutectic silumin alloyed with Cr atoms under compression plasma flows impact are presented in this work. The formation of metastable $\text{Al}_{74}\text{Cr}_{20}\text{Si}_6$ in the alloyed layer was found. Annealing of alloyed sample at 550°C resulted in dissolution of $\text{Al}_{74}\text{Cr}_{20}\text{Si}_6$ and formation of $\text{Al}_{13}\text{Cr}_4\text{Si}_4$. The structural-phase transformation in the modified layer led to silumin hardening.

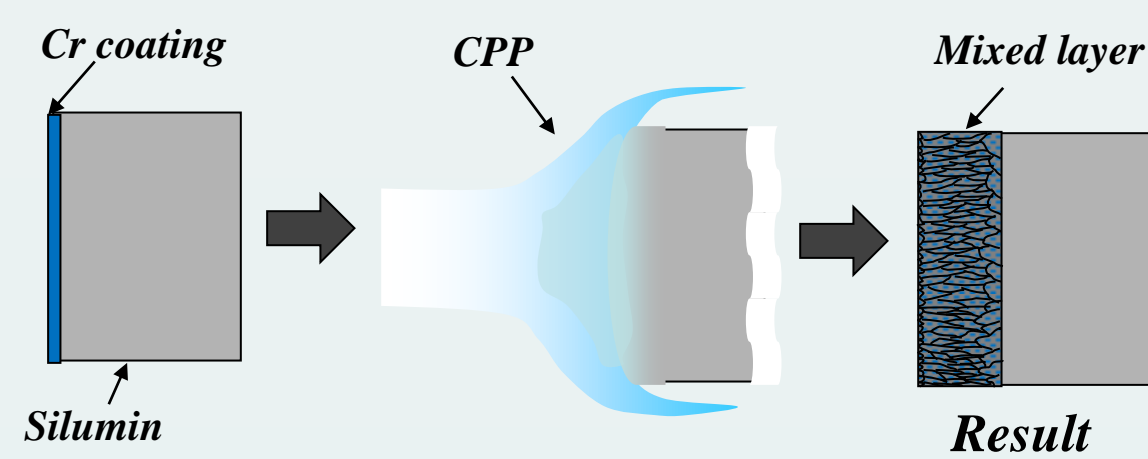
Investigation objects: 12,6 at.% Si; 0,5 at.% Cu; 2,7 at.% Mg; 0,3 at.% Ni; 0,3 at.% Fe; 0,2 at.% Mn.

Experimental procedure

Vacuum-arc Cr coating deposition

Parameters of deposition:

- Cathode arc current – 100 A
- Coating deposition time – 10 min
- Coating thickness – 2 μm



Compression plasma flows impact

Parameters of the CPF treatment:

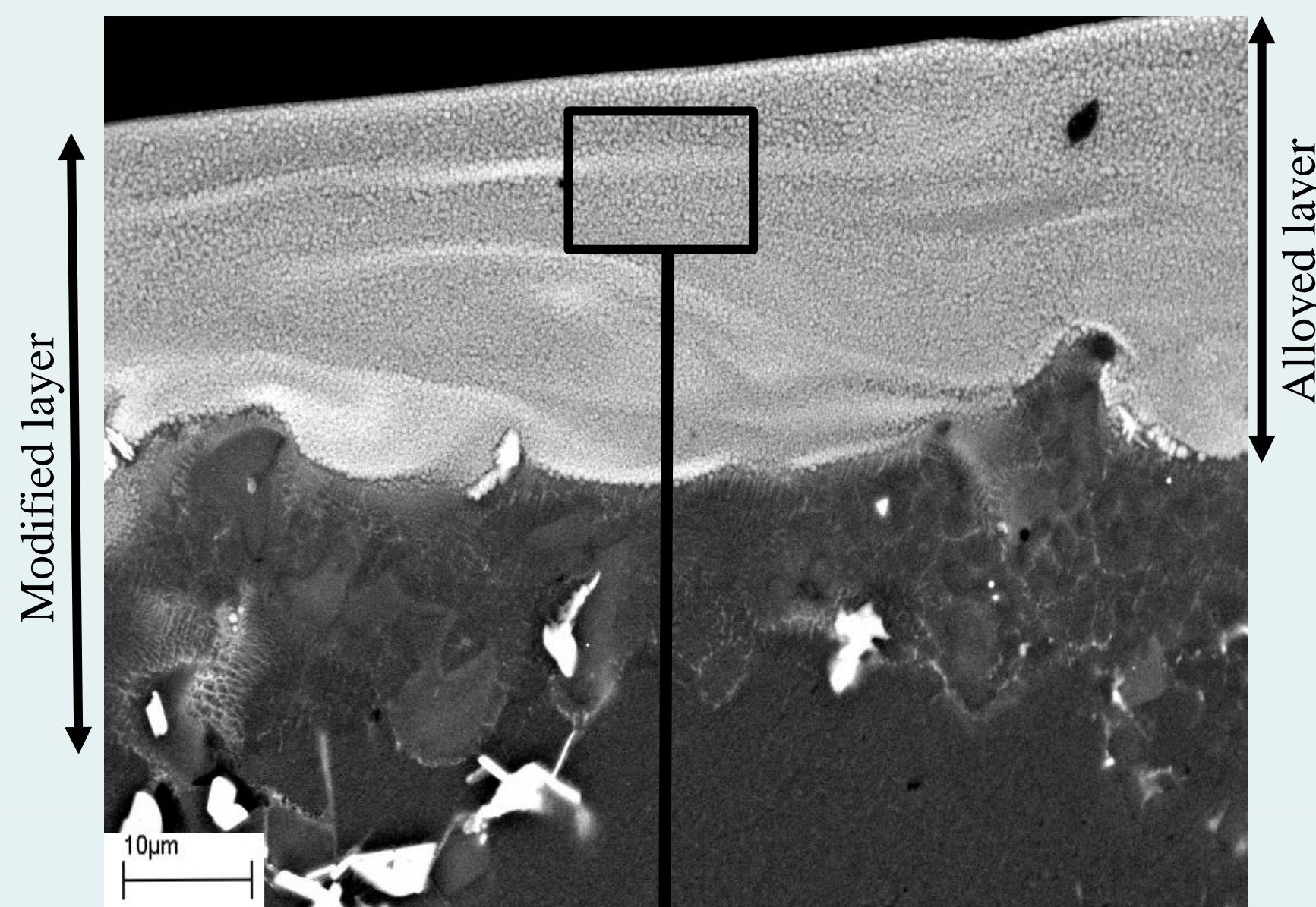
- Number of pulses – 3
- Nitrogen residual atmosphere (pressure 400 Pa)
- Voltage on the capacitor battery – 4.0 kV
- Absorbed energy density (Q) – 17 J/cm²
- Pulse duration 100 μs

Annealing

Parameters of annealing:

- Temperature – 450-550°C
- Time – 2h

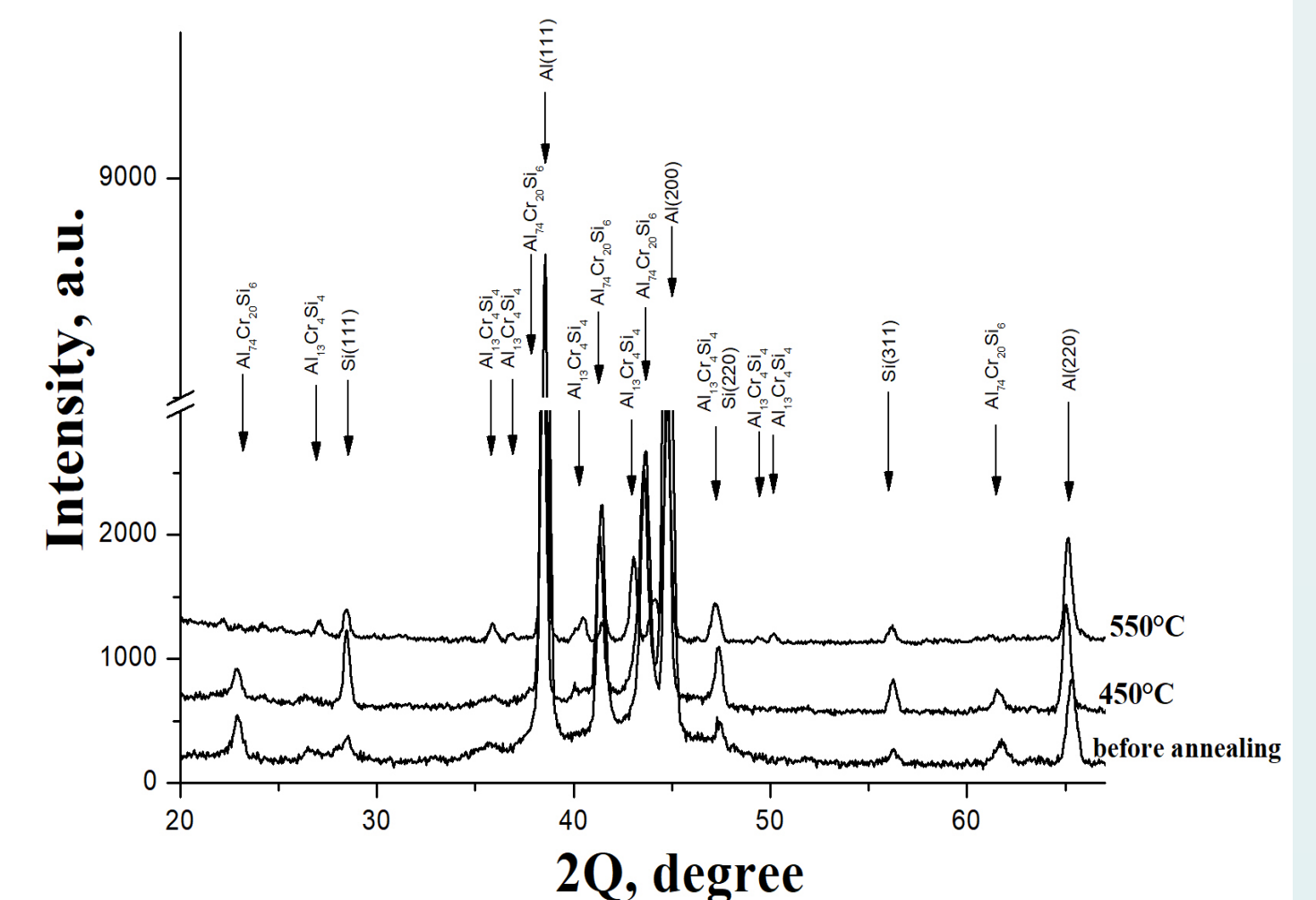
Cross-section after CPF impact



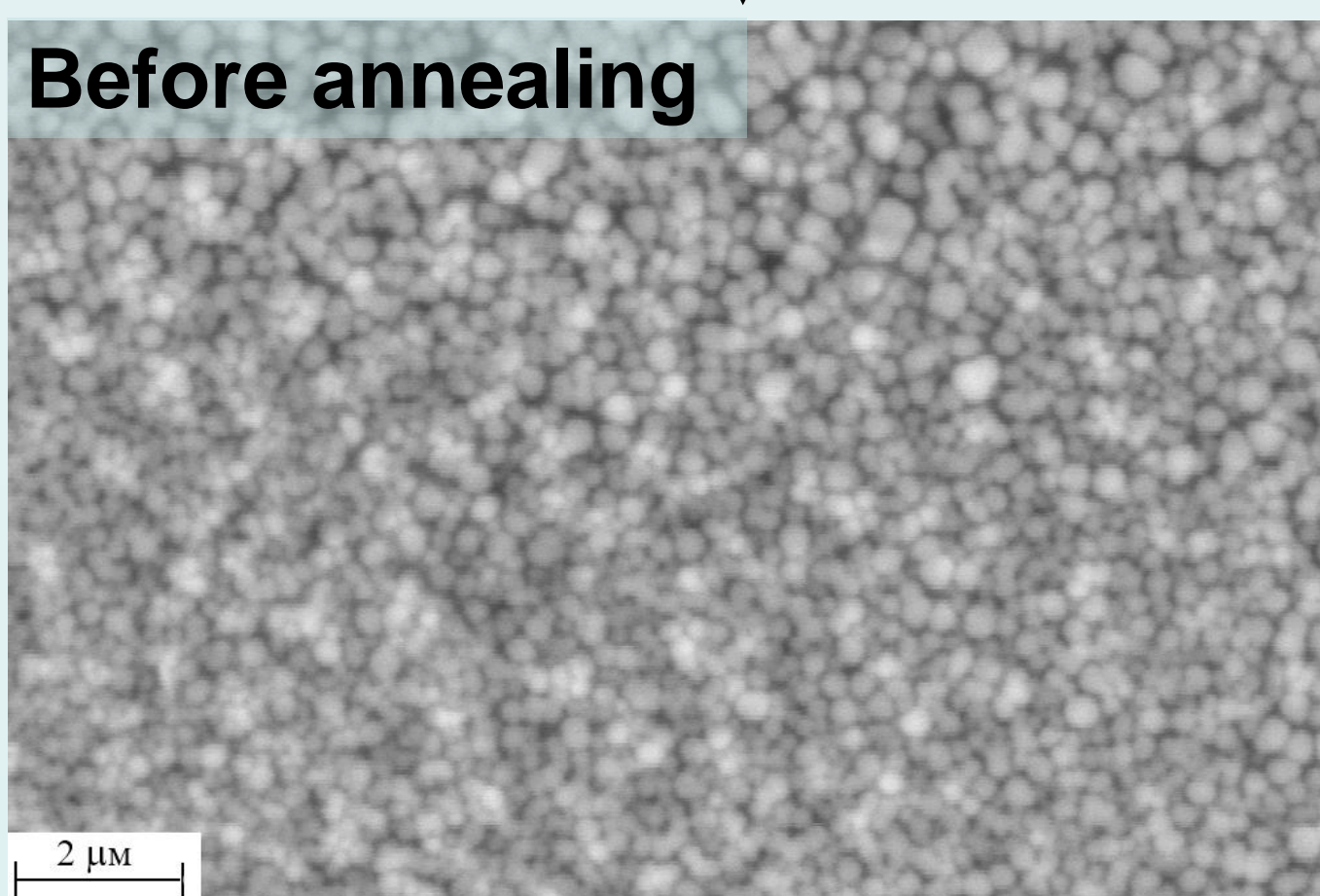
After CPF treatment:

- formation of alloyed layer with thickness $\sim 25 \mu\text{m}$
- alloyed layer contains $\text{Al}_{74}\text{Cr}_{20}\text{Si}_6$ precipitates with size of 100-300 nm
- decrease of lattice parameter of Al from $a=0,4051\pm0,0002 \text{ nm}$ to $a=0,4041\pm0,0002 \text{ nm}$ \rightarrow formation of supersaturated solid solution Al(Si)

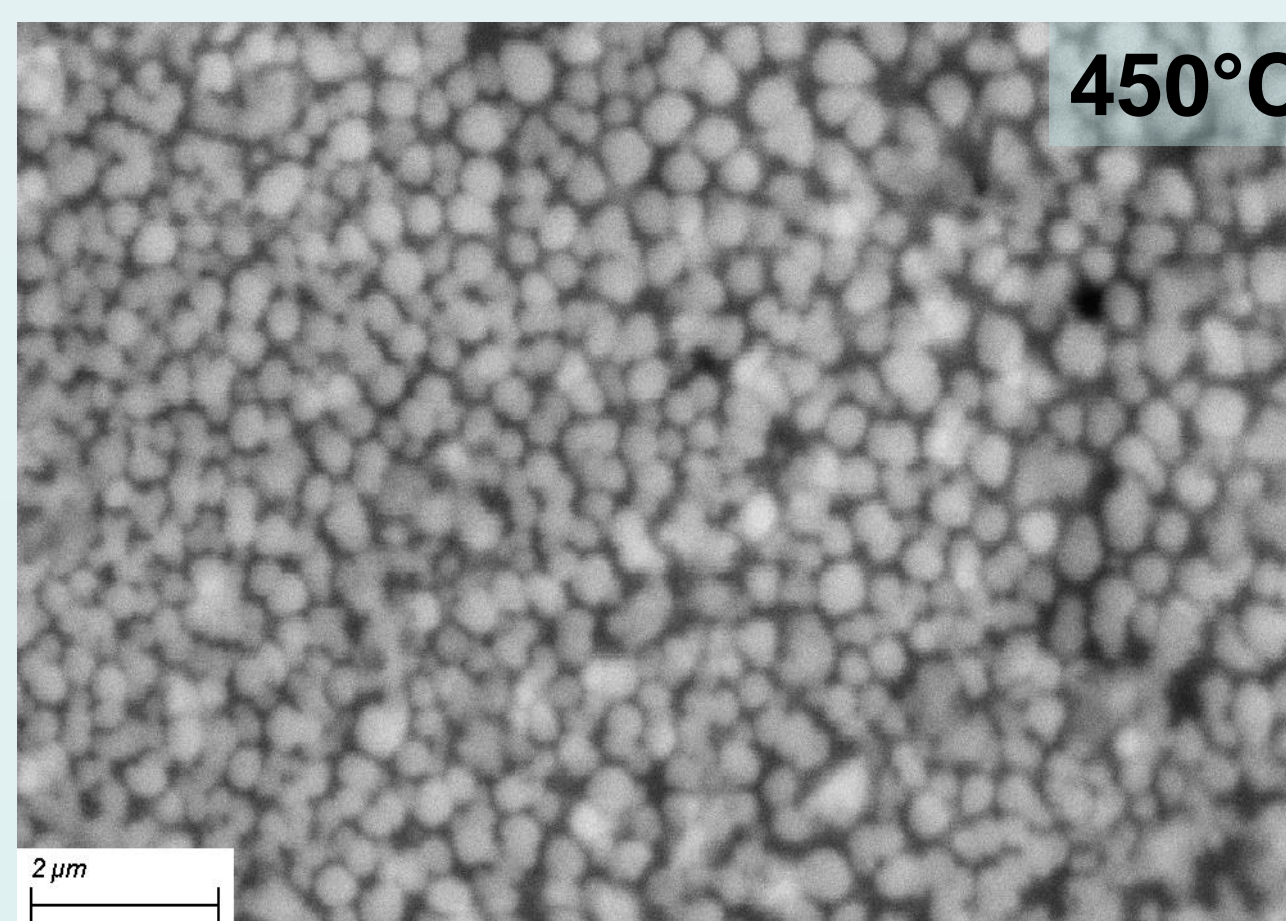
XRD



Before annealing

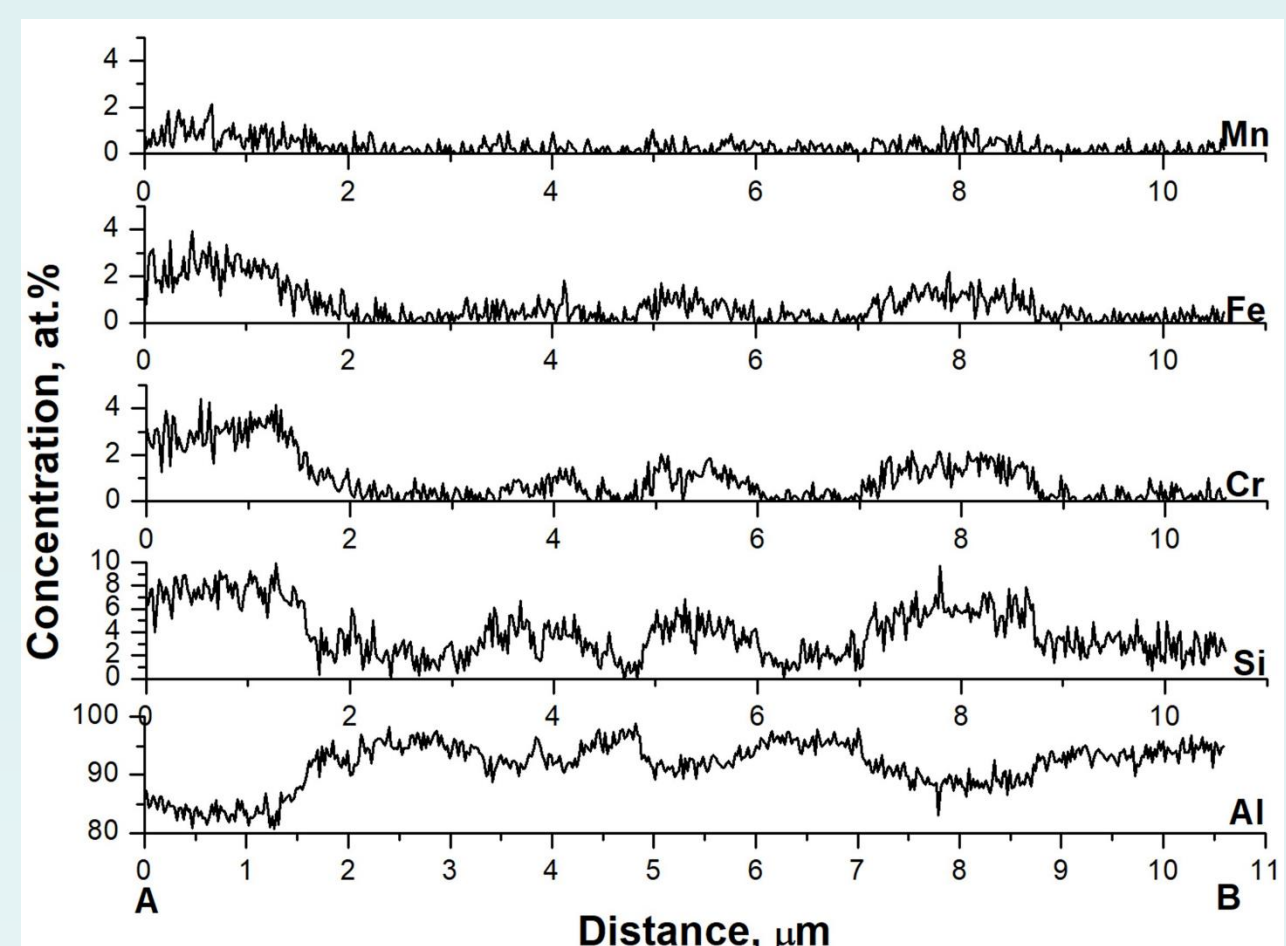
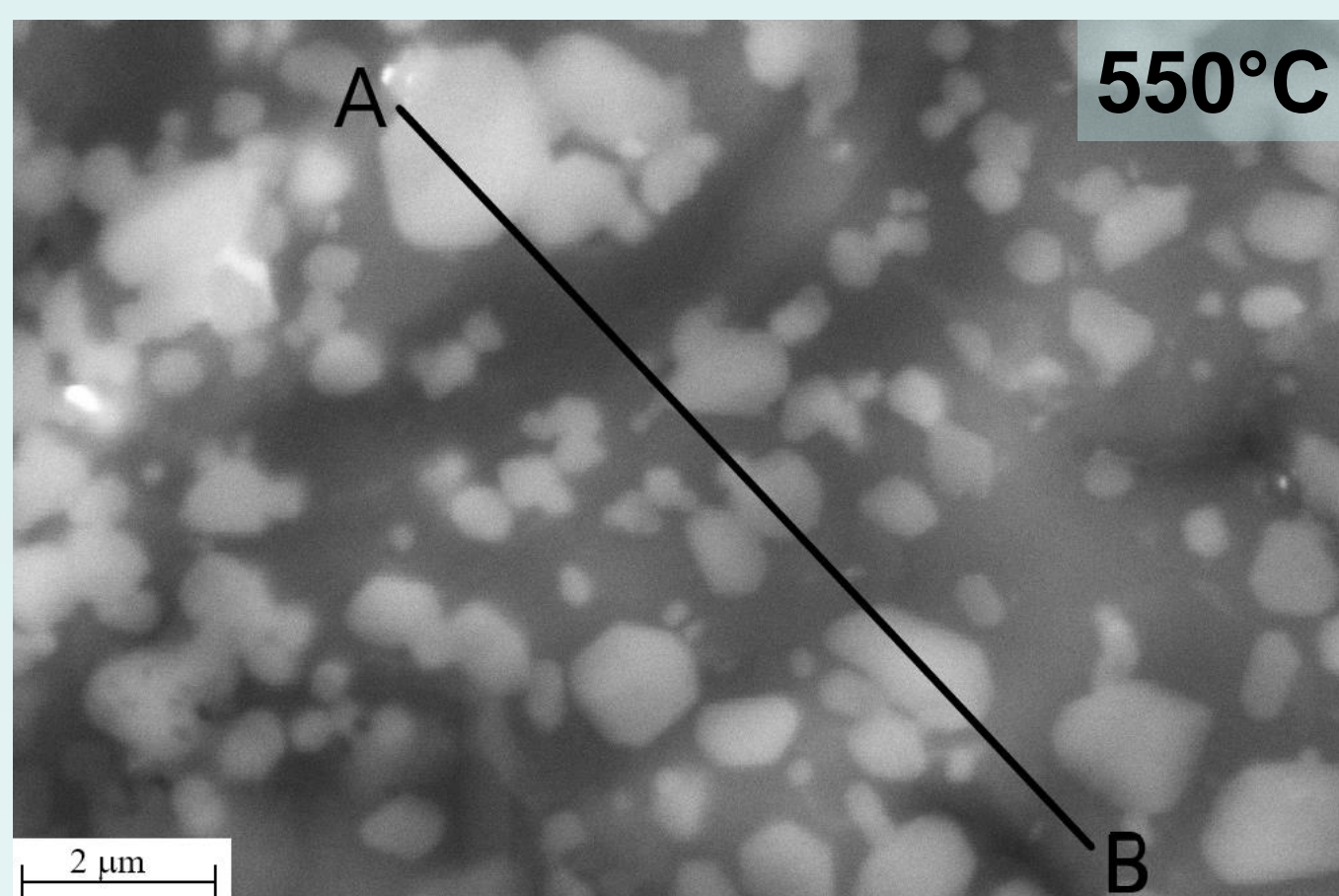


450°C



After annealing:

- according to XRD increasing of aluminum lattice parameter to the value $a=0,4053\pm0,0002 \text{ nm}$ and increasing of intensity of Si diffraction lines \rightarrow decomposition of solid solution Al(Si)
- $\text{Al}_{74}\text{Cr}_{20}\text{Si}_6$ remains stable under during annealing at 450°C but its coagulation is observed
- decomposition of $\text{Al}_{74}\text{Cr}_{20}\text{Si}_6$ and formation of $\text{Al}_{13}\text{Cr}_4\text{Si}_4$ during annealing at 550°C
- according to X-ray microanalysis the composition of $\text{Al}_{13}\text{Cr}_4\text{Si}_4$ phase includes Fe and Mn



Alloying with Cr atoms eutectic silumin makes it possible to increase its strength characteristics. The microhardness of the initial silumin is 1.3 GPa, and that of the CPP-treated one is $\sim 3 \text{ GPa}$. The microhardness of the alloyed near-surface layer in the studied samples subjected to annealing is higher than the microhardness of the initial annealed samples not subjected to alloying ~ 2 times. In the samples annealed at 450°C for 2 h, the microhardness is 1.6 GPa, while in the original, annealed under the same conditions, it is 0.8 GPa.